

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

Sheet 1 of 1

Complete if Known			
Application Number	10/676,411		
Filing Date	September 30, 2003		
First Named Inventor	Robert Bristol		
Art Unit	1756		
Examiner Name	Daborah Chacko Davis		
Attorney Docket Number			

NON PATENT LITERATURE DOCUMENTS					
Examiner Initials*	Cite No.1	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	Ţ²		
:		THOMAS, M.D.R., et al., "Electron-Beam Exposure Characteristics of a novel Ru-PMMA Composite Resist, Microelectronic Eng., 41/42 pp 327-330, 1998.	·		
		NAKANO, Atsuro, et al., "Dependence of Acid Yield on Acid Generator in Chem. Amplified Resist for Post-Optical Lith.", Japan J. of Applied Phys., vol. 44, no. 7B, 5832-5835, 2005			
:					
			,		
			-		

Examiner	Date	
Signature	Considered	

^{*}Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication.

^{&#}x27;Applicant's unique citation designation number. 'Applicant is to place a check mark here if English language Translation is attached.